

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

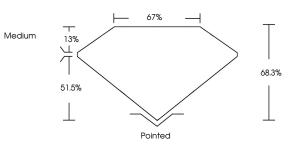
August 25, 2024		
IGI Report Number	LG649406783	
Description	LABORATORY GROWN DIAMOND	
Shape and Cutting Style	CUT CORNERED RECTANGULAR MODIFIED BRILLIANT	
Measurements	10.27 X 7.10 X 4.85 MM	
GRADING RESULTS		
Carat Weight	3.09 CARATS	
Color Grade	G	
Clarity Grade	VS 1	
ADDITIONAL GRADING INFORMATION		
Polish	EXCELLENT	

	The second se
EXCELLENT	Symmetry
NONE	Fluorescence
1371 LG649406783	Inscription(s)

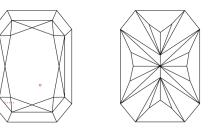
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG649406783 Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.



Sample Image Used

COLOR

D E F	GHIJ	Faint	Very Light	Light
CLARITY	WS ¹⁻²	VS ¹⁻²	SI ¹⁻²	1-3
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

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Measurements	10.27 X 7.10 X 4.85 MM
GRADING RESULTS	
Carat Weight	3.09 CARATS
Color Grade	G
Clarity Grade	VS 1
Medium	
T N	68.3%
51.5%	

ADDITIONAL GRADING INFORMATION

Polish EXCELLENT Symmetry EXCELLENT Fluorescence NONE nscription(s) 1/57/LG649405783 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type Ila		
Fluorescence NONE nscription(s) (JG) LG649406783 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
nscription(s) (Fig) LG649406783 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	EXCELLENT
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Fluorescence	NONE
created by Chemical Vapor Deposition (CVD) growth process.	nscription(s)	低到 LG649406783
	created by Chemical Vapor process.	

Pointed





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